



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Patricia B. Smith, et al.

Docket No: TI-25250

Serial No: 09/199,829

Conf. No: 4119

Examiner: Julio J. Maldonado

Art Unit: 2823

Filed: 11/25/1998

For: HYDROGEN PLASMA PHOTORESIST STRIP AND POLYMERIC RESIDUE  
CLEANUP PROCESS FOR OXYGEN-SENSITIVE MATERIALS

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PRELIMINARY AMENDMENT

Dear Sir:

Prior to the examination of the above identified application, Applicants respectfully  
submit the following amendments and remarks.

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